

Nourish & Restore Cream

Personal Care

from Scott Bader

Formulation reference: FM00364/A

Phase	Trade Name	INCI Ingredients	Function	% w/w	Supplier
A	Deionised Water	Aqua	Solvent	Up to 100%	
	Dissolvine NA2	Disodium EDTA	Chelating Agent	0.05	Brenntag
	Sodium Benzoate Granular	Sodium Benzoate	Preservative	0.25	OQEMA
B	Citric Acid Monohydrate	Citric Acid	pH Adjuster	0.15	Univar
C	Cobiogum	Caesalpinia Spinosa Gum	Thickener	0.20	IMCD
D	Timiron Super Red	Mica	Pearl/ Radiance	0.50	Azelis
	Timiron Flash	Mica	Pearl/ Radiance	0.50	Azelis
E	Naissance Vegetable Glycerine No 806	Glycerin	Humectant/ Moisturising	2.00	Naissance
	Cetiol Ultimate	Undecane (and) Tridecane	Light Emollient/ Skin Softening	2.00	BASF
	Myritol 318	Caprylic/Capric Triglyceride	Emollient/ Skin Softening	2.00	BASF
	Isopropyl Myristat	Isopropyl Myristate	Emollient/ Skin Softening	2.00	BASF
	Texique Lux5	C13-15 Alkane (and) Caprylic/ Capric Triglyceride	Natural Emollient	1.00	Scott Bader

A daily gentle moisturising cold process cream with an amino acid complex to give deep down moisturisation. Containing **Texiterra Sea Buckthorn Fruit Pulp Oil** to provide strong healthy-looking skin and **Texiterra Kalahari Melon Seed Oil**, a natural source of Vitamin E, known for its hydrating and nourishing qualities. **Texiterra Raspberry Seed Oil** with its high level of essential fatty acids helps with cell regeneration to promote silky new skin and **Texique Lux5** aids with enhanced spreadability and silky feel. Containing a combination of natural based **Texique HE10** and **Texique HE20** to emulsify, stabilise and provide a unique light sensory feel.



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	Texiterra Kalahari Melon Seed Oil	Citrillus Lanatus (Watermelon Seed) Oil	Natural Oil/ Skin Softening	2.00	Scott Bader
	Texiterra Raspberry Seed Oil	Rubus Idaeus Seed Oil	Natural Oil/ Skin Softening	0.50	Scott Bader
	Texiterra Sea Buckthorn Fruit Pulp Oil	Hippophae Rhamnoides Fruit Oil	Natural Oil/ Skin Softening	0.03	Scott Bader
	Phenoxyethanol RCH	Phenoxyethanol	Preservative	0.60	Ashland
	Prodew 600	Betaine (and) Sodium PCA (and) Sodium Lactate (and) PCA (and) Serine (and) Alanine (and) Glycine (and) Glutamic Acid (and) Lysine HCl (and) Threonine (and) Arginine (and) Proline (and) Water	Active Amino Acid Complex/ Moisturising	1.00	Rahn
F	Texique HE10	Sodium Acrylate/ Sodium Acryloyldimethyl Taurate Copolymer, C13-15 Alkane, Coco-Glucoside	Emulsifier/ Thickener/ Rheology Modifier	4.00	Scott Bader
	Texique HE20	AMPS/HEMA Crosspolymer, C13-15 Alkane, Coco-Glucoside	Emulsifier/ Thickener/ Rheology Modifier	2.00	Scott Bader
G	Mixed Tocopherols	Tocopherol (and) Helianthus annuus Seed Oil	Active-Vitamin E/ Antioxidant	0.10	The Soap Kitchen
		Parfum	Fragrance	QS	

Method

1. Weigh out phase A and mix until completely dissolved.
2. Add phase B and mix until fully dissolved.
3. Whilst homogenising, add phase C and homogenise gently until completely dispersed.
4. Whilst homogenising, add phase D and homogenise gently until completely dispersed.
5. Add phase E individually, mixing well between additions.
6. Whilst homogenising at low speed add phase F materials individually. Homogenise until smooth and uniform emulsion achieved.
7. Pre-mix phase G materials together until uniform. Add to main batch and mix until uniform.

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